(19) Europäisches Patentamt
European Patent Office
Office européen des brevets

(11) EP 0 746 037 A3

(12) EUROPEAN PATENT APPLICATION

(88) Date of publication A3:
15.04.1998 Bulletin 1998/16

(43) Date of publication A2:
04.12.1996 Bulletin 1996/49

(21) Application number: **96108453.0**

(22) Date of filing: **28.05.1996**

(51) Int. Cl.[6]: **H01L 29/43**, H01L 21/335, H01L 29/80

(84) Designated Contracting States:
DE FR

(30) Priority: **02.06.1995 US 459855**

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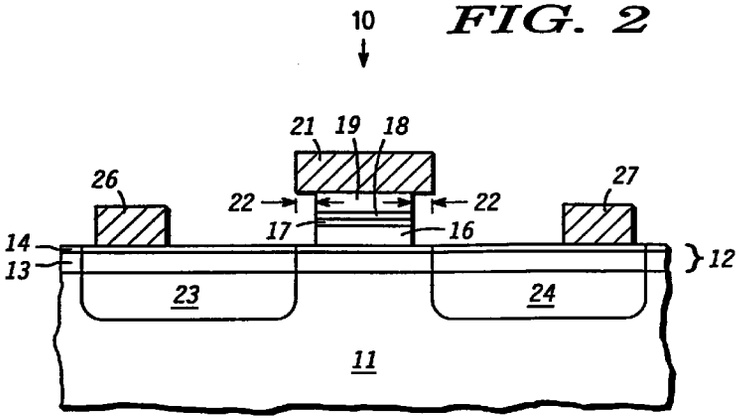
(54) N-type HIGFET and method

(57) An N-type HIGFET (10) utilizes two etch layers (17,18) to form a gate insulator (16) to be shorter than the gate electrode (21). This T-shaped gate structure facilitates forming source (23) and drain (24) regions that are separated from the gate insulator (16) by a distance (22) in order to reduce leakage current and increase the breakdown voltage.

FIG. 2



EP 0 746 037 A3

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EUROPEAN SEARCH REPORT

Application Number
EP 96 10 8453

DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cl.6)
X	A. DOMINGO ET AL.: APPLIED PHYSICS LETTERS, vol. 52, no. 17, 25 April 1988, pages 1395-1397, XP002052198	10	H01L29/43 H01L21/335 H01L29/80
A	* figure 2 *	1-9	

A	S. UMEBACHI ET AL.: IEEE TRANSACTIONS ON ELECTRON DEVICES , August 1975, pages 613-614, XP002052044 * figure 1 *	1-10	

A	M.D. FEUER ET AL.: IEEE ELECTRON DEVICE LETTERS, vol. edl-8, no. 1, January 1987, pages 33-35, XP002052045 * figure 1 *	1-10	

			TECHNICAL FIELDS SEARCHED (Int.Cl.6)
			H01L

The present search report has been drawn up for all claims

Place of search	Date of completion of the search	Examiner
BERLIN	15 January 1998	Juhl, A

CATEGORY OF CITED DOCUMENTS

X : particularly relevant if taken alone
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